

Supplementary Materials: High-Power Impulse Magnetron Sputter-Deposited Chromium-Based Coatings for Corrosion Protection

Yen-Chun Liu ¹, Shih-Nan Hsiao ^{2,*}, Ying-Hung Chen ^{1,3}, Ping-Yen Hsieh ^{1,3} and Ju-Liang He ^{1,3}

¹ Department of Materials Science and Engineering, Feng Chia University, No. 100, Wenhwa Rd., Seatwen District, Taichung City 40724, Taiwan; ycliu@o365.fcu.edu.tw (Y.-C.L.); chenyingh@o365.fcu.edu.tw (Y.-H.C.); pyhsieh@mail.fcu.edu.tw (P.-Y.H.); jlhe@o365.fcu.edu.tw (J.-L.H.)

² Center for Low-Temperature plasma Sciences, Nagoya University, Furocho, Chikusaku, Nagoya City 464-0863, Japan

³ Institute of Plasma, Feng Chia University, No. 100, Wenhwa Road, Seatwen District, Taichung City 407102, Taiwan

* Correspondence: hsiao@plasma.engg.nagoya-u.ac.jp

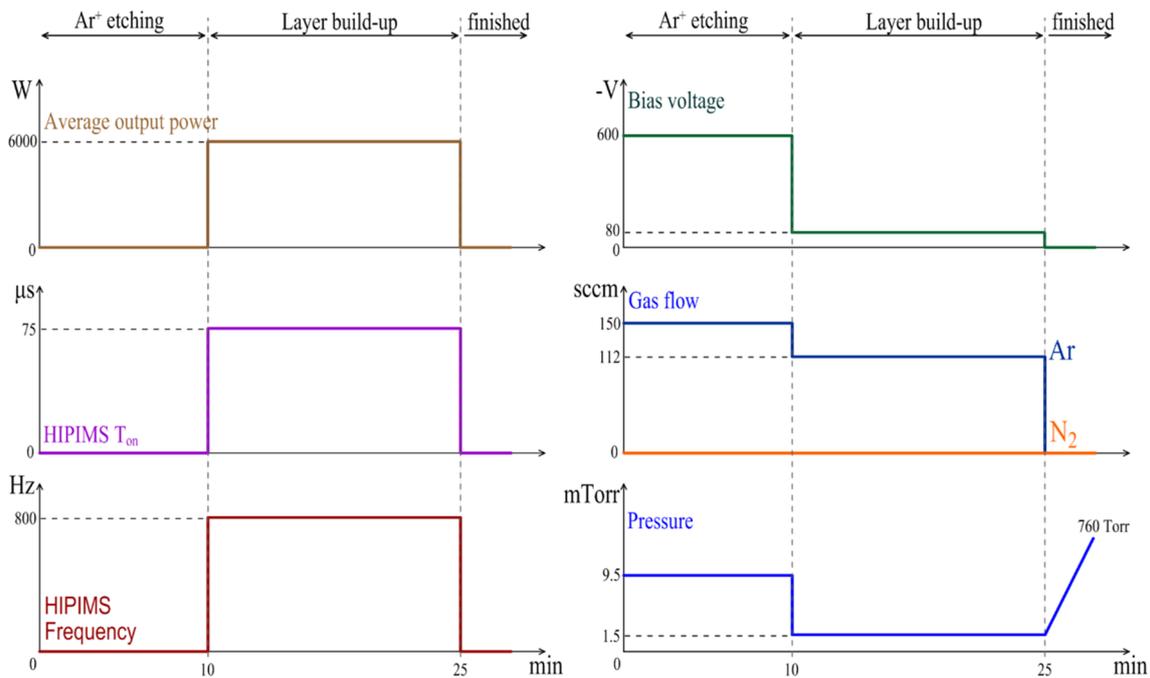


Figure S1. Schematic of the parameter setups and variation as a function of deposition time for the Cr single-layer coating (HS1).

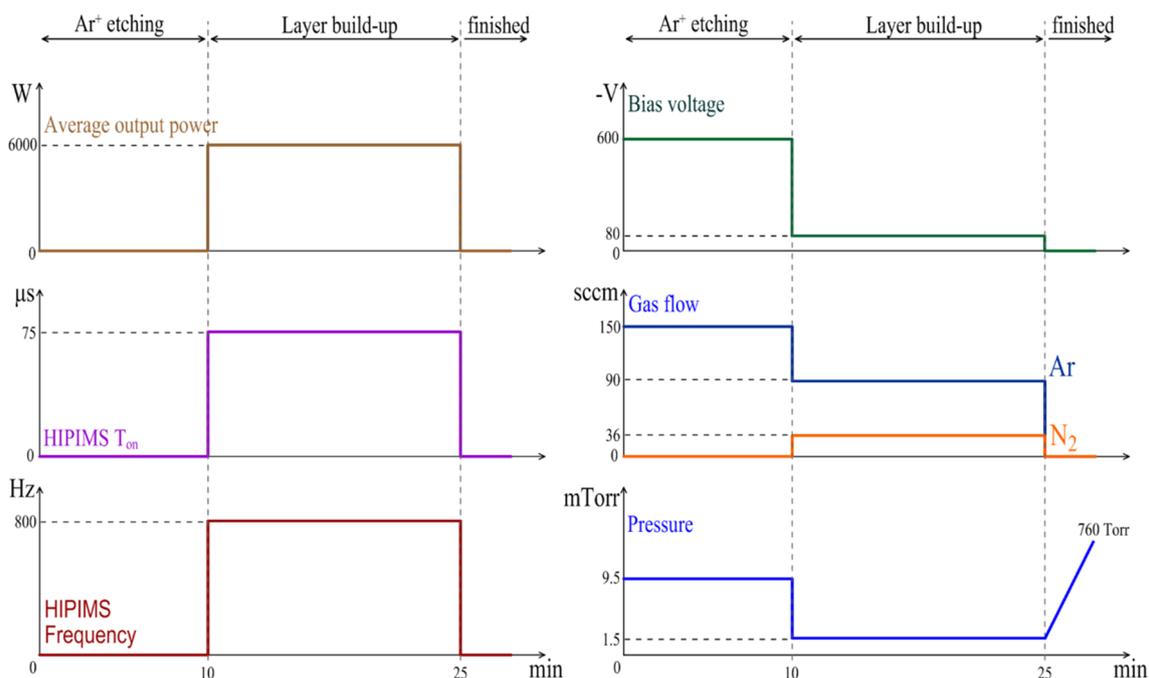


Figure S2. Schematic of the parameter setups and variation as a function of deposition time for the CrN single-layer coating (HS2).

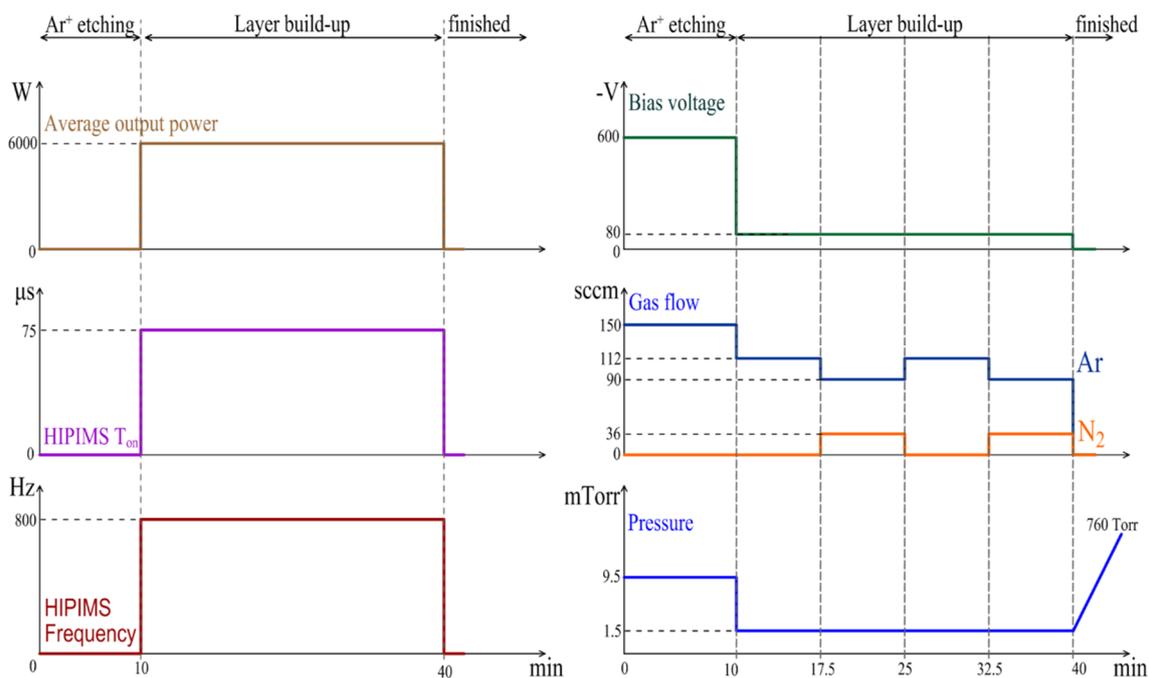


Figure S3. Schematic of the parameter setups and variation as a function of deposition time for the multilayer CrN coating (HM1).

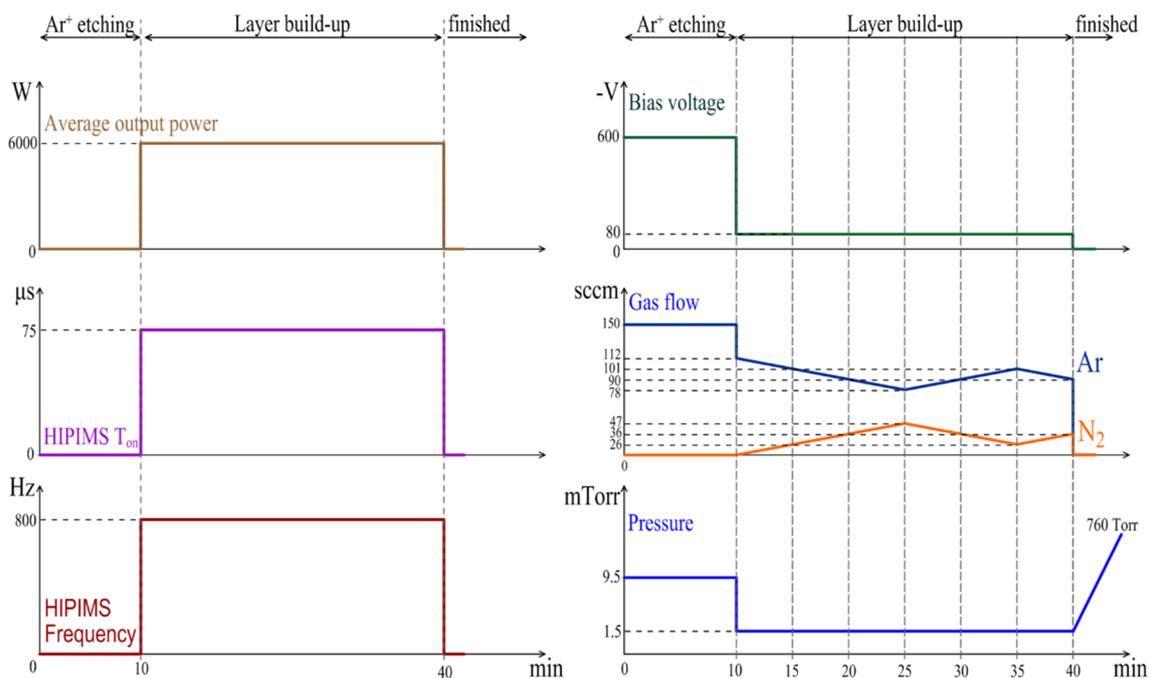


Figure S4. Schematic of the parameter setups and variation as a function of deposition time for the multilayer CrN coating (HM2).

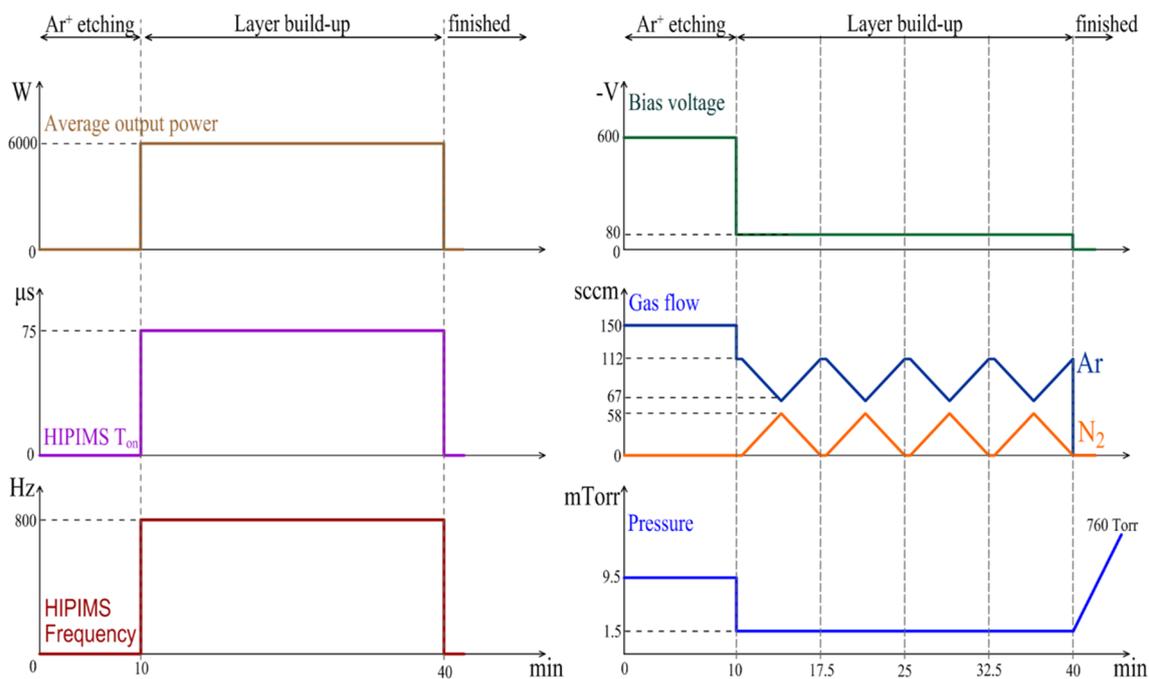


Figure S5. Schematic of the parameter setups and variation as a function of deposition time for the multilayer CrN coating (HM3).

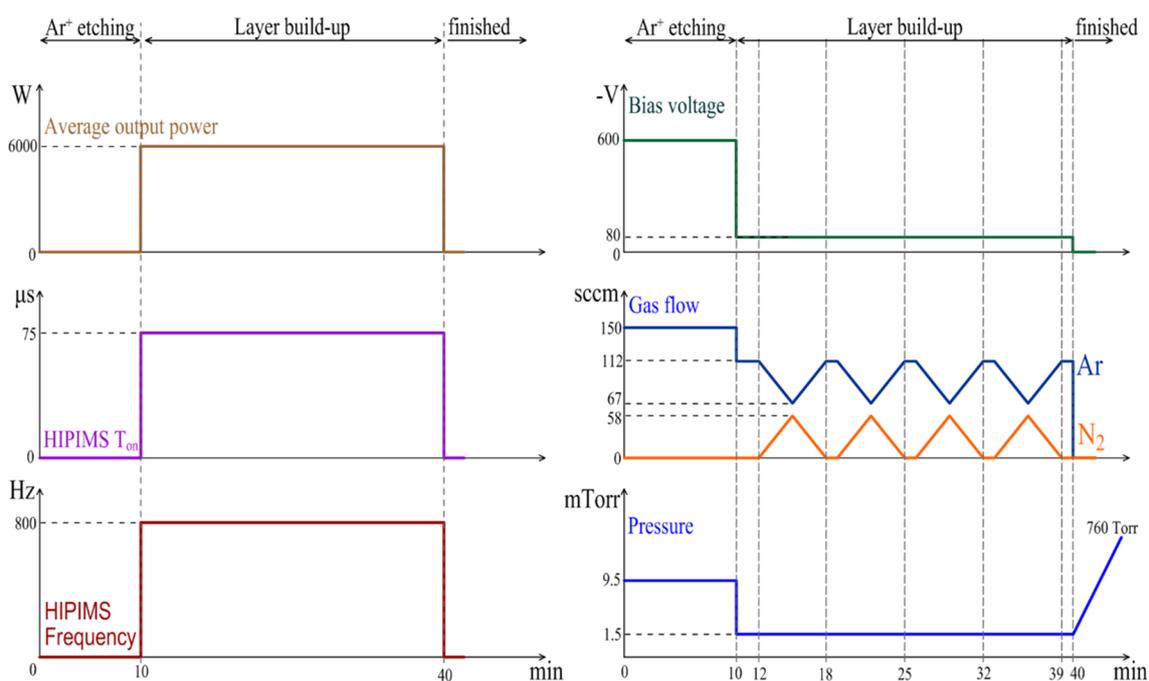


Figure S6. Schematic of the parameter setups and variation as a function of deposition time for the multilayer CrN coating (HM4).

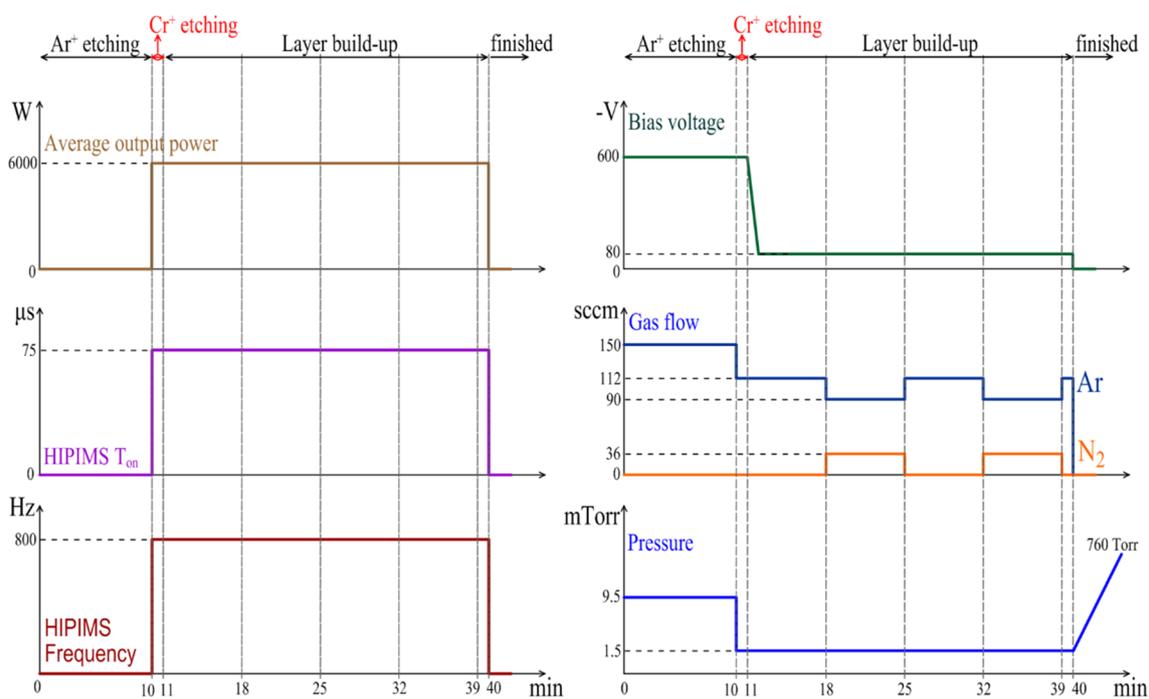


Figure S7. Schematic of the parameter setups and variation as a function of deposition time for the multilayer CrN coating (HMS1).

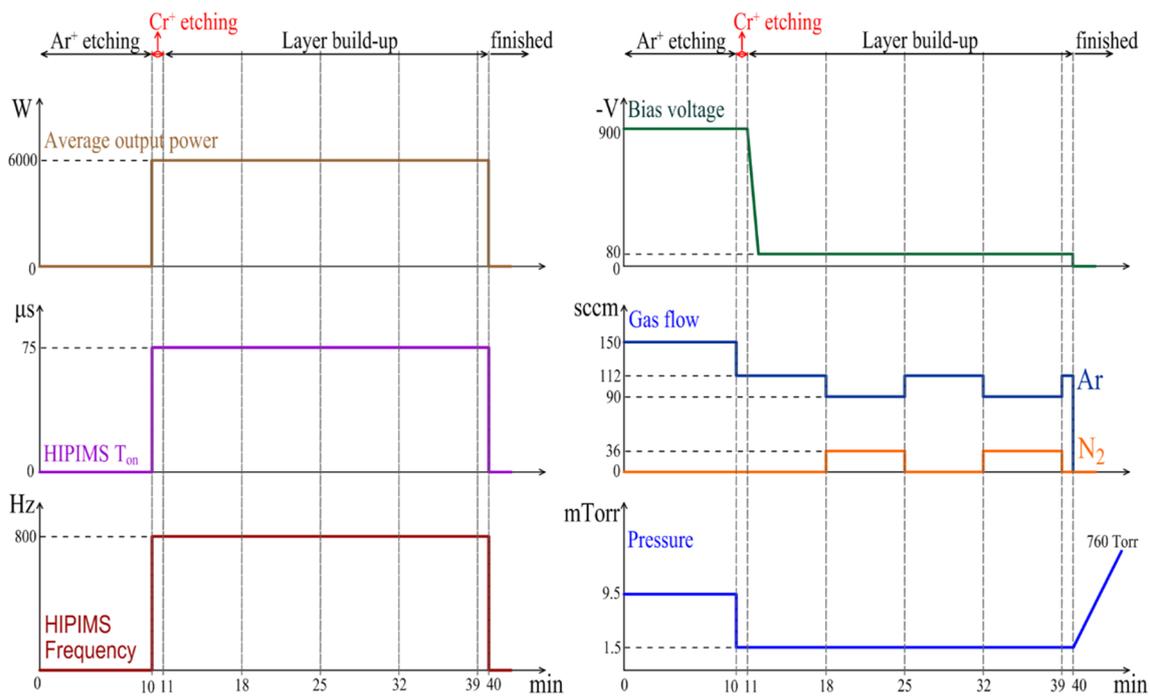


Figure S8. Schematic of the parameter setups and variation as a function of deposition time for the multilayer CrN coating (HMS2).